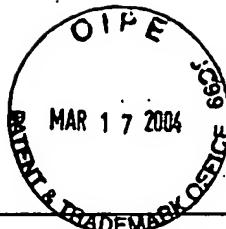


FORM PTO-1449 (MODIFIED)

LIST OF PUBLICATIONS FOR
APPLICANT'S INFORMATION
DISCLOSURE STATEMENT



Applicant(s): Brian A. Floyd
Docket No.: YOR920030585US1
Serial No.: 10/731,341
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Group: 2817

10/731,341

U.S. PATENT DOCUMENTS

EXAMINER	DOCUMENT NO.	DATE	NAME	CLASS/SUBCLASS	FILING DATE IF APPROPRIATE
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FOREIGN PATENT DOCUMENTS

EXAMINER	DOCUMENT NO.	DATE	COUNTRY	CLASS/SUBCLASS	TRANSLATION YES NO
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OTHER DOCUMENTS

EXAMINER	REF NO.	AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.
<input checked="" type="checkbox"/>		1. L. Tran et al., "High Performance, High Yield Millimeter-Wave MMIC LNAs Using InP HEMTs," IEEE IMS Digest, p. 9-12, June 1996.
<input checked="" type="checkbox"/>		2. M. Siddiqui et al., "GaAs Components for 60GHz Wireless Communication Applications," GaAs Mantech Conference, pp. 1-4, April 2002.
<input checked="" type="checkbox"/>		3. A. Fujihara et al., "High Performance 60-GHz Coplanar MMIC LNA Using InP Heterojunction FETs with AlAs/InAs Superlattice Layer," IEEE IMS Digest, p. 21-24, June 2000.
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<input checked="" type="checkbox"/>		5. K. Onodera et al., "V-Band Monolithic Low-Noise Amplifiers Using Ion-Implanted n+-Self-Aligned GaAs MESFETs," IEEE Microwave Guided Wave Letters, Vol. 9, No. 4, pp. 148-150, April 1999.
<input checked="" type="checkbox"/>		6. B. Jagannathan et al., "Self-Aligned SiGe NPN Transistors with 285 GHz f_{MAX} and 207 GHz f_T in a Manufacturable Technology," IEEE Electron Device Letters, Vol. 23, No. 5, pp. 258-260, May 2002.

NGUYEN, K

4/21/05

Examiner

Date Considered

Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.